



Attorney's Docket No. 5308-157IP2

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: Das et al.

Serial No.: 10/045,542

Filed: October 26, 2001

For: METHOD OF FABRICATING AN OXIDE LAYER ON A SILICON
CARBIDE LAYER UTILIZING AN ANNEAL IN A HYDROGEN
ENVIRONMENT

Confirmation No.: 3570

Group Art Unit: 1762

Examiner: Michael. E. Barr

Date: September 26, 2003

Mail Stop RCE
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

Applicants provide the present Amendment to address the issues raised in the Notice of Allowance mailed June 27, 2003. Applicants provide the present Amendment pursuant to the rules stated in revised 37 C.F.R. 1.121 that became effective on July 30, 2003.

Amendments to the Specification begin on page 2 of this paper.